

MURANG'A UNIVERSITY COLLEGE

(A Constituent College of Jomo Kenyatta University of Agriculture and Technology)

DEPARTMENT: MECHANICAL ENGINEERING

LEVEL: DIPLOMA

CLASS: DME/P/A/14D

ACADEMIC YEAR: 2015

UNIT: ANALOGUE ELECTRONICS

UNIT CODE: SME 1205

TIME: 2 HOURS

DATE: 7TH AUGUST 2015

SPECIAL

Instructions to candidates

This paper contains FOUR Questions

Question ONE is Compulsory

ATTEMPT any 2 Other Questions FROM Section B

You should have the following for this examination;

- Drawing instruments
- Scientific calculator

Mobile phones not allowed in exam rooms

| 1. a) i) Sketch the Schematic symbols of the PNP and NPN transistors and label the three | terminals. |
|---|------------------|
| ii) With the aid of sketches explain how an NPN transistor works. iii) With the aid of sketches name THREE methods of transistor configurations. iv) From first principles show that $\beta=\alpha/1-\alpha$ and $\alpha=\beta/1+\beta$ | (8mks) |
| | DNI |
| b) With the aid of a diagram explain the Volt Ampere characteristics of a forward biased Junction of a common base transistor configuration. | (12mks) |
| c) Define the following terms | |
| I) Nucleus II) Valence electrons | (2mks) (2mks) |
| d.) Define the following terms | |
| I) Nucleus | (2mks) |
| II) Valence electrons | (2mks) |
| e) Define the following terms with respect to the P-N junction | |
| I) Breakdown voltage. | (1mks) |
| II) Knee voltage. | (1mks) |
| SECTION B | |
| 2. a) i) Sketch a well labeled V-I Characteristics curve of a Zener diode. | |
| ii) Explain the difference between Valence band and conduction band. | |
| iii) With the aid of a diagram explain the transistor stabilizer circuit. | (10mks) |
| b) i) Define the term depletion layer.ii) With the aid of a diagram explain the Operation of JFET | |
| iii) Explain five diode parameters | (10mks) |
| 3. a) Explain the following terms: | |
| i) Doping. | |
| ii) Pentavalent atoms | |
| iii) Depletion region | (6mks) |
| b) Differentiate between intrinsic and extrinsic semi-conductor materials. | (4mks) |

| c) Explain the effect of temperature on intrinsic semi conductors. | (4mks) | |
|---|--------|--|
| d) Explain how a p-type semiconductor material is formed. | (6mks) | |
| 4. a) Explain the meaning of potential barrier for a PN junction. | (3mks) | |
| b) With the aid of circuit or block diagrams, explain the following terms as used in PN | | |
| semiconductors diodes | | |
| i) Forward bias | | |
| ii) Reverse bias | (6mks) | |
| c) With the aid of characteristic curves, describe the biasing of a PN junction diode. | | |
| | (4mks) | |
| d) Define the term <i>rectification</i> as used in power supplies. | (2mks) | |